

Course Establishment Form Outline

Fall 2010

Division:	Math/Science/Social Sciences	Program/Dept:	Nanotechnology
Course Number:	NANO 220	Credits: 5	Variable:
Course Title:	Nano/Microfabrication		
Inst. Intent:	21 Professional Technical	CIP:	15.0614
	Fee: Yes	Type : Laboratory Fee	

Degree/Certificate Requirement:	Yes X	No:
Name of Degree/Certificate:	Nanotechnology AAS-T; Certificate in Nanotechnology	
Distribution Requirement for AA/AS:	NA	
Transfer Status to 4-year institution:	Yes	No: X
If yes, please describe:		
Course length:	1 quarter	Class Size: 17
Course Contact Hours:	66	
Lecture: 44	Lab: 22	Clinical:
		Other:
		System: 66
Prerequisite:	Yes: X	No:
If yes, please describe:		
NANO 101, CHEM& 121 and MATH& 098 or by instructor permission		
Required Placement Tests:	Yes	No X
If yes, please describe: N/A		
Comments:		
PHYS& 121 recommended		

Course Description:
This course teaches the fabrication technologies used in the nano/micro fabrication laboratory and production environments. Subject matter includes cleanroom basics and proper technique; vacuum technology; lithography; methods of physical and chemical materials deposition and etching.

NSCC General Education Learning Outcomes and/or Related Instructional Outcomes (for technical courses) Met by Course:

Knowledge

Methodologies, facts, theories, and perspectives within and across disciplines

Intellectual and Practical Skills, including

- Critical thinking and problem solving
- Quantitative reasoning

Course Outcomes/Learning Objectives:

Upon successful completion of the course, students should be able to:

- I. demonstrate a broad, and functional understanding of a variety of physical and chemical materials deposition and etching methods used in nano/micro fabrication and the vacuum systems they use
- II. compare and contrast top-down and bottom-up fabrication technologies used across a range of industries.
- III. describe the steps used in a nano/micro fabrication process and how varying process parameters at a given step will affect the outcome of the process.
- IV. demonstrate the proper use of several specific fabrication tools, including proper cleanroom procedure
- V. become active contributors in a nano/micro fabrication environment.

Topical Outline and/or Major Divisions:

1. Chemical and Cleanroom Safety and Procedures
 - a. Chemical Hygiene
 - i. Information resources
 - ii. Materials handling
 - b. Safety
 - i. Protection and safety equipment
 - ii. Emergency planning and response
 - c. Cleanroom basics
 - i. Ratings, filtration, regulation,
 - ii. Proper technique
2. Crystallization-Deposition Techniques
 - a. Physical
 - i. Bulk crystal growth
 - ii. Evaporation
 - iii. Sputtering
 - iv. Doping
 1. Diffusion
 2. Ion implantation
 - v. Micro-printing
 - b. Chemical
 - i. Liquid phase epitaxy
 - ii. Molecular beam epitaxy
 - iii. Chemical vapor deposition (CVD)

1. Atmospheric and low pressure CVD
 2. Plasma enhanced CVD
 3. Metallorganic CVD
3. Lithography
 - a. Spin coating
 - b. Photolithography
 - i. Negative process
 - ii. Positive process
 - iii. Soft lithography
 - iv. Lift-off
 - v. Materials and equipment
 - c. Electron beam lithography
 - d. X-ray lithography
 4. Etching and Material Modification
 - a. Wet chemical etching
 - b. Plasma etching
 - c. Rapid thermal processing and annealing
 5. Nanomaterials fabrication
 - a. Nanophase chemistry and synthesis
 - i. Bottom-up synthesis
 - ii. Molecular self assembly
 - iii. Top-down synthesis
 - b. Nanomaterial composites
 - i. Bulk materials with nanoenhanced properties
 - ii. Nanoscale formation of meso-structures
 - c. Molecular machines and nanofactories
 6. Vacuum Science
 - a. Vacuum generation
 - i. Compression pumps
 - ii. Momentum transfer pumps
 - iii. Entrapment pumps
 - b. Vacuum measurement
 - i. Mechanical gauges
 - ii. Thermal-conductivity gauges
 - iii. Ionization gauges
 - iv. RGA

Course Requirements (Expectations of Students)

Students will be expected to...

- 1) Participate in class activities.
- 2) Read text and article assignments.
- 3) Finish written homework assignments and present results to class.
- 4) Take scheduled quizzes and examinations
- 5) Attend all lab activities
- 6) Demonstrate the ability to perform specific competencies listed under "Course Outcomes/Learning Objectives."

Methods of Assessment/Evaluation:

As determined by instructor, but usually includes at least exams, written homework assignments and class participation.

Final grades are assigned according to published grading standards for the course

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Required and Supplemental Text(s) and/or Materials: As determined by instructor.
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Outline Developed by: Vincenzo Casasanta / Mark Hesel **Date:** 6/20/06

Outline Revised by: Alissa Agnello **Date:** 3/17/10